0			2001/09/2 7 16:50	US-P GPUB	9 and 10 and 12	14	L13	BRS	13
0			001/09/ 17:05	PU -S	(Nitrogen or N) with concentrat\$4	708	L12	BRS	12
0		,,,	001/09/ 16:49	US-P GPUB	9 and 10	18	L11	BRS	11
0		10	2001/09/2 7 16:48	US-P GPUB	(oxynitride or silicon adj Nitrogen adj oxygen or si adj n adj o) and (semiconductor adj film)	20	L10	BRS	10
0			2001/09/2 7 16:48	UŚ-P GPUB	TFT or (thin adj2 film adj2 transistor\$2)	502	L9	BRS	9
0		, ,	2001/09/2 7 17:32	USPA T	1 and 2 and 4 and 5 and 6	10	L8	BRS	8
0			001/09/ 16:44	USPA T	1 and 2 and 4 and 5	18	L7	BRS	7
0			09/ 50	USPA T	(oxygen or o) with concentrat\$4	49142	16	BRS	6
0			001/09/ 16:50	USPA T	(silicon or Si) with concentrat\$4	18243	L5	BRS	5
0			001/09/ 16:49	USPA T	(Nitrogen or N) with concentrat\$4	63380	L4	BRS	42
0			001/09/ 16:44	USPA T	1 and 2	72	L3	BRS	ω
0			2001/09/2 7 16:53	USPA	(oxynitride or silicon adj Nitrogen adj oxygen or si adj n adj o) and (semiconductor adj film)	144	L2	BRS	Ν
0			2001/09/2 7 16:53	USPA T	TFT or (thin adj2 film adj2 transistor\$2)	10398	L1	BRS	Н
rs ro	Error Definition	Comment	Time Stamp	DBs	Search Text	Hits	변 ⁷ # <u>(</u> /	Туре	

0			7 16:55	JPO	22 and 23	2	L24	BRS	24
0			1/09/6:59	JPO	(oxynitride or silicon adj2 Nitrogen adj2 oxygen or si adj2 n adj2 o) and (semiconductor adj film)	4	L23	BRS	23
0			2001/09/2 7 17:15	JРО	TFT (film tran	11402	L22	BRS	22
0			2001/09/2	EPO	kyni icon 2 ox 2 n nico	0	L21	BRS	2 1
0			2001/09/2 7 16:53	EPO	18 and 19	0	L20	BRS	20
0			9/	EPO	(oxynitride or silicon adj Nitrogen adj oxygen or si adj n adj o) and (semiconductor adj film)	 	L19	BRS	19
0			2001/09/2	EPO	TFT or (thin adj2 film adj2 transistor\$2)	1953	L18	BRS	18
0			2001/09/2 7 16:51	US-P GPUB	9 and 10 and 12 and 14 and 16	7	L17	BRS	17
0				US-P GPUB	(oxygen or o) with concentrat\$4	434	L16	BRS	16
0			2001/09/2 7 16:51	US-P GPUB	9 and 10 and 12 and 14	9	L15	BRS	15
0			2001/09/2 7 17:06	US-P GPUB	(silicon or Si) with concentrat\$4	359	L14	BRS	14
H H H	Error Definition	Comment	Time Stamp	DBs	Search Text	Hits	#_	Туре	

	Туре L #	변 #	Hits	Search Text	DBs	Time Stamp	Comment	Error Definition	HHE
25	BRS	L25	13245	TFT or (thin adj2 13245 film adj2 transistor\$2)	DERW	2001/09/2 7 17:07			0
26	BRS	L26	ω	(oxynitride or silicon adj2 Nitrogen adj2 Nitrogen adj2 oxygen or si adj2 n adj2 o) and (semiconductor adj film)	DERW	2001/09/2			0
27	BRS	L27 0	0	25 and 26	DERW	2001/09/2 7 17:01			0

Hits Search Text DBs Stamp	0		10	7 17:32	T	1 and 4 and 5 and 6	150	L45	BRS	45
L31 O 25 and 30 DERW 2001/09/2 DERW 2	0		2	001/09/ 17:28	EPO	8 and 41 and 42 3	4	4	BRS	44
L31 0 25 and 30 DERW 2001/09/2 Comment DERW 2001/09/2 L31 0 25 and 30 DERW 2001/09/2 Comment Comment DERW 2001/09/2 Comment	0			001/09/ 17:27	יטי	oxygen or o) wi oncentrat\$4	35	4	BRS	43
L31 Description Descript	0			001/09/ 17:27	EPO	icon or Si) wi entrat\$4	00	4	BRS	42
L31 O 25 and 30 DERW 2001/09/2 Cox\$nitride or slicon Adj2 Nitrogen adj2 DERW 2001/09/2 D	0			001/09/ 17:27	EPO	trogen or N) wit centrat\$4	50	4	BRS	41
L31 0 25 and 30 DERW 2001/09/2 Comment Com	0			001/09/ 17:16	JРО	2 and 36 and 37 8	7	4	BRS	40
L # Hits Search Text DBs Time Comment Error Stamp St	0			001/09/ 17:16	JPO	2 and 36 and	0	ω	BRS	39
L # Hits Search Text DBs Stamp Sta	0			001/09/ 17:27	JРО	oxygen or o) wit oncentrat\$4	096	ω	BRS	38
L31 0 25 and 30 DERW 2001/09/2 Coxynitride or adj2 Nitrogen adj2 or salicon (semiconductor adj) ENT 7 17:03 DERW 2001/09/2	0			001/09/ 17:27	JPO	silicon or Si) wit oncentrat\$4	42	ω	BRS	37
L31 O 25 and 30 DERW 2001/09/2 Comment Comment Comment Stamp	0			001/09/ 17:27	JPO	Nitrogen or N) wit oncentrat\$4	175	ω	BRS	36
Search Text DBs Time Stamp S	0			001/09/ 17:07	DERW	2 and 33 and 34 a 5	4	ω	BRS	35
Poe L # Hits Search Text DBs Time Stamp Comment Stamp Error Definition L31 0 25 and 30 DERW 2001/09/2 ENT 7 17:03 DERW 2001/09/2 ENT 7 17:14	0			001/09/ 17:14	DERW ENT	oxygen or o) wi oncentrat\$4	36	ω	BRS	34
Search Text DBS Time Stamp S	0			001/09/ 17:14	DERW ENT	icon or Si) wit entrat\$4	426	ω	BRS	33
L31 0 25 and 30 DERW 2001/09/2 Stamp Soxinitride or oxinitride or silicon adj2 Nitrogen adj2 n (semiconductor adj) L30 5 Film) L30 L	0			001/09/ 17:14	DERW ENT	en or N) wi rat\$4	618	ω	BRS	32
pe L # Hits Search Text DBs Stamp Stamp Sefinition L31 0 25 and 30 ENT 7 17:03	0			001/09/ 17:03	DERW	(ox\$nitride or xinitride or silico xinitride or silico dj2 Nitrogen adj2 n xygen or si adj2 n dj2 o) and semiconductor adjin)		30	BRS	3 1
L # Hits Search Text DBs Stamp S Definition	0			001/09/ 17:03	DERW	5 and 3		31	BRS	30
	H O H	Error finition		Time Stamp	DBs	earch	rt l		Туре	

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